

/ 509472

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Application Information

Title Line One:: PHOTOMASK BLANK, PHOTOMASK, METHODS OF
Title Line Two:: MANUFACTURING THE SAME AND METHOD OF
Title Line Three:: FORMING MICROPATTERN
Title Line Four::

09/509472

422 Rec'd PCT/PTO 30 MAR 2000

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Continuity Information

>This application is a:: National Stage of
Application One:: PCT/JP99/04124
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Prior Foreign Applications

Foreign Application One:: 10-217433
Filing Date:: July 31, 1998
Country:: JAPAN
Priority Claimed:: YES
Foreign Application Two::
Filing Date::
Country::
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Foreign Application Three::
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Priority Claimed::